

P/1250-262

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

New York, New York

Shuzo NAGAMI et al.

Date: December 24, 2003

Serial No.: 10/671,817

Group Art Unit: ---

Filed: September 26, 2003

Examiner: ---

For: SUBSTRATE PROCESSING APPARATUS AND SUBSTRATE
PROCESSING METHOD

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December 24, 2003

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Respectfully submitted,

James A. Finder

Registration No.: 30,173

OSTROLENK, FABER, GERB & SOFFEN, LLP

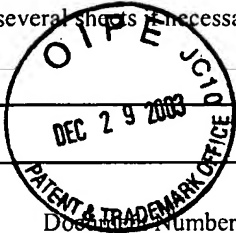
1180 Avenue of the Americas

New York, New York 10036-8403

Telephone: (212) 382-0700

JAF:msd
Enclosures

APPLICANT'S ART CITATION (Use several sheets if necessary)		Application 10/671,817		OFGS File No. P/1250-262	
		Applicant Shuzo NAGAMI et al.			
		Filing Date September 26, 2003		Group Art Unit ---	



U.S. PATENT DOCUMENTS						
Examiner Initial	Document Number	Date MM-YYYY	Name	Class	Sub-class	Filing Date If Appropriate
	US-4,960,141	10-1990	Lenck et al.	134	61	
	US-4,643,774	02-1987	Kishida et al.	134	1	
	US-4,714,086	12-1987	Kishida et al.	134	83	
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FOREIGN PATENT DOCUMENTS							
	Document Number	Date MM-YYYY	Country	Class	Sub-class	Translation	
						Yes	No
	1-130771	05-1989	Japan				X
	4-58686	09-1992	Japan				X

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)		

Examiner	Date Considered
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